

ltem	Minimum Capability	Maximum Capability	Tolerance	Remarks
Metal Finishing: Hal Lead Free (SnCuNi)	, , ,			Sn100C Alloyage
Chemical Tin (Inm.Sn) (*)			_	(*) Subcontracted
Chemical Silver (Inm.Ag)				
Electroless Ni Inmersion Gold (ENIG)	Ni: 3 μm	Ni: 7 μm		
Final Finishing:	Au: 0,04 μm	Au: 0,07 μm		
Liquid PhotoImageable Solder Mask				A wide range of colours
				-
Ink Legend	-	-	-	A wide range of colours
Conductive Carbon Ink				
Peelable Mask				
Raw Material:				
FR-4 Tg Standard	130 ºC	140ºC	-	Depending on the manufacturer
FR-4 High Tg	150 ºC	180 ºC		
Number of layers	4	8	-	Under request (consult delivery time): 105 μm
Base Copper (inner or outter layers)	17 μm	70 μm	-	Or equivalent tolerance
Plated Through Hole (PTH)	200 μm	-	+ 0,10 / - 0,05 mm	Or equivalent tolerance
Non Plated Through Hole (NPTH)	300 μm	-	+ 0,10 / -0 mm	O tolerancia equivalente



Item		Minimum Capability	Maximum Capability	Tolerance	Remarks
Width and isolation of copper conductors in outter layers (Base	\leftrightarrow	100 μm (17 μm)	тахинан саравису	± 25%	Remarks
Copper)		125 μm (35 μm)	-	± 30%	-
		200 μm (70 μm)		± 30%	
Width and isolation of copper conductors in inner layers (Base	\leftrightarrow	100 μm (17 μm)		± 25%	
Copper)		100 μm (35 μm)	-	± 25%	
		200 μm (70 μm)		± 30%	
Copper annular ring in outter layers (Base Copper)		100 μm (17 μm)			
		125 μm (35 μm)	-	-	Recommendation: for a good soldering surface, for component holes ≥ 200 µm
		250 μm (70 μm)			
Copper annular ring in inner layers (Base Copper)		150 μm	-	-	-
Minimal isolation in inner layers (power and ground planes)		250 μm	-	-	-
Distance between NPTH and copper conductor		200 μm	-	-	-



		,			
Item		Minimum Capability	Maximum Capability	Tolerance	Remarks
Distance between copper conductor and board edge (routed)		150 μm	-	-	-
Misalignement between copper and PTH	000	-	-	± 100 μm	-
Misalignement between outline and PTH			-	± 150 μm	
Distance between a copper conductor and theorical scoring axis		500 μm	-	-	-
Maximum hole to be plugged with peelable mask		0,30 mm	1,80 mm	-	-
Distance between peelable mask and copper pad		0,80 mm	-	-	-



Item		Minimum Capability	Maximum Capability	Tolerance	Remarks
Solder Mask annular ring		50 μm	-	-	-
Solder Mask bridge		100 μm	-	-	-
Distance between solder mask clearance and copper conductor		50 μm	-	-	-
Misalignement between solder mask and copper		-	-	± 150 μm	-
Ink Legend width	R23	100 μm	-	-	-
Misalignement between ink legend and copper		-	-	± 200 μm	-



Item	Minimum Capability	Maximum Capability	Tolerance	Remarks
Carbon ink width	600 μm	-	-	-
Separation between carbon conductors	400 μm	-	-	-
Platted Wall thickness	20 μm	60 μm	-	Average: 25 μm
Scoring positioning (taken on axis)	-	-	± 150 μm	-
Core thickness after scoring process	200 μm	-	± 150 μm	Standard: 300 μm
Misalignement between top-bottom scoring blades	-	-	± 150 μm	-





	Item	Minimum Capability	Maximum Capability	Tolerance	Remarks
Final Thickness		0,80 mm	3,2 mm	± 10 % (e > 1,0 mm) ± 100 μm (e ≤ 1,0 mm)	Depending on Multilayer stack-up and number of layers
Bow & Twist	La medición se realiza con las cuatro esquinas en contacto con la base Puntos A, B y C en contacto con la base	-	0,75% of diagonal	-	-
Final pcb dimensions (routing)		15 x 15 mm	510 x 370 mm	< 30 mm: ± 0.10 mm < 120 mm: ± 0.15 mm >120 mm: ± 0.20 mm	-
Other		-	-	-	According to IPC-A-600 revision G Standard

REMARKS

- 1.- The extra Cu deposition is performed by an electrolytic process; therefore It is extremely convenient that the density of Cu on both sides is similar. This reduces the irregularities in total Cu thickness, warping and bending, reduction in PTH diameters and the excess of Cu on conductors.
- 2.- It is important to eliminate nonfunctional pads on the inner layers (usually placed where PHTs go with no connection on that particular layer) in order to avoid short circuits
- 3.- For class VI and VII PCBs the use of tear drops is highly recommended to compensate the quantity of Cu on both sides